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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
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10/612,096

07/02/2003

Joo-Won Lee

SAM-0429

3427

7590

08/12/2004

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EXAMINER

NADAV, ORI

ART UNIT

PAPER NUMBER

2811

DATE MAILED: 08/12/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary

Application No.

10/612,096

Applicant(s)

LEE ET AL.

Examiner

ori nadav

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-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 01 July 2004.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1-18 is/are pending in the application.
- 4a) Of the above claim(s) 11-18 is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1-10 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☒ The drawing(s) filed on 02 July 2003 is/are: a) ☒ accepted or b) ☐ objected to by the Examiner.
- Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
- Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☒ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☒ All b) ☐ Some * c) ☐ None of:
1. ☒ Certified copies of the priority documents have been received.
2. ☐ Certified copies of the priority documents have been received in Application No. _____.
3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- 1) ☒ Notice of References Cited (PTO-892)
- 2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948)
- 3) ☐ Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)
Paper No(s)/Mail Date _____
- 4) ☐ Interview Summary (PTO-413)
Paper No(s)/Mail Date. _____
- 5) ☐ Notice of Informal Patent Application (PTO-152)
- 6) ☐ Other: _____

DETAILED ACTION

Election/Restrictions

Applicant's election without traverse of claims 1-10 on 7/1/2004 is acknowledged.

Drawings

The formal drawings filed on 7/02/2003 are acceptable.

Information Disclosure Statement

If applicant is aware of any relevant prior art, he/she requested to cite it on form PTO-1449 in accordance with the guidelines set forth in M.P.E.P. 609.

Claim Rejections - 35 USC § 112

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Claims 2-4 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention. The claimed limitation of a length of the electrode lines is greater than an ordinary length of conventional electrode lines by a predetermined length, as recited in claim 2, is indefinite because the phrase "an ordinary length of conventional electrode" renders the claim unascertainable.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

Claims 1-10, insofar as in compliance with 35 U.S.C. 112, are rejected under 35 U.S.C. 103(a) as being unpatentable over Ejiri (6,770,974) in view of Applicant Admitted Prior Art (AAPA).

Ejiri teaches in figure 13 and related text an electrode line structure of a semiconductor device comprising:

a semiconductor substrate 10, and

an electrode line 18 formed on the semiconductor substrate, the electrode line having an inclined end in the long axis direction;

wherein the electrode line includes a first line unit 18b, which substantially functions as an electrode line, a second line unit 18c, which includes the inclined end in the long axis direction and which is separated from the first line unit by a predetermined distance, and an insulating plug 24, which is interposed between the first line unit and the second line unit and electrically insulates the first line unit from the second line unit.

Ejiri does not disclose that the device comprises plurality of electrode lines.

AAPA teaches in figure 1B plurality of electrode lines 20 having inclined ends.

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It would have been obvious to a person of ordinary skill in the art at the time the invention was made to use plurality of electrode lines in Ejiri's device in order to use the device in a practical application.

Regarding claims 2 and 3, it would have been obvious to a person of ordinary skill in the art at the time the invention was made to use the length of the electrode lines greater than an ordinary length of conventional electrode lines by a predetermined length and the insulating plug is formed at a predetermined position of each of the electrode lines such that the first line unit has the ordinary length in Ejiri's device in order to use the device in an application which requires specific electrode length.

Regarding claim 4, Ejiri teaches in figure 13 and related text the length of the second line unit is greater than a width of the electrode lines and less than the ordinary length.

Regarding claims 5, 8 and 10, AAPA teaches the first line unit and the second line unit each comprise a conductive layer and a hard mask layer, respectively, a spacer is formed on the inclined end in the long axis direction of the second line unit, wherein the electrode lines comprise one of word lines and bit lines. It would have been obvious to a person of ordinary skill in the art at the time the invention was made to form the first line unit and the second line unit each with a conductive layer and a hard mask layer, respectively, to use a spacer on the inclined end in the long axis direction of the second line unit, and to use the electrode lines as one of word lines and bit lines in Ejiri's device

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in order to form the electrode lines in a conventional method using hard mask, in order to provide better protection to the electrode lines , and in order to use the device in an application which requires word lines or bit lines, respectively.

Regarding claims 6 and 7, Ejiri teaches a conductive layer comprises a material containing tungsten. It would have been obvious to a person of ordinary skill in the art at the time the invention was made to use electrode lines comprising a material containing tungsten an a hard mask layer comprises a silicon nitride layer or a silicon oxynitride layer in Ejiri's device in order to provide better conductivity and insulation to the electrode lines.

Regarding claim 9, it would have been obvious to a person of ordinary skill in the art at the time the invention was made to form the insulating plug of a material of which the spacer is formed in Ejiri's device in order to simplify the processing steps of making the device.

Papers related to this application may be submitted to Technology center (TC)

2800 by facsimile transmission. Papers should be faxed to TC 2800 via the TC

2800 Fax center located in Crystal Plaza 4, room 4-C23. The faxing of such

papers must conform with the notice published in the Official Gazette, 1096 OG

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30 (November 15, 1989). The Group 2811 Fax Center number is (703) 308-7722 and 308-7724. The Group 2811 Fax Center is to be used only for papers related to Group 2811 applications.

Any inquiry concerning this communication or any earlier communication from the Examiner should be directed to *Examiner Nadav* whose telephone number is **(571) 272-1660**. The Examiner is in the Office generally between the hours of 7 AM to 4 PM (Eastern Standard Time) Monday through Friday.

Any inquiry of a general nature or relating to the status of this application should be directed to the **Technology Center Receptionists** whose telephone number is **308-0956**



O.N.
8/6/04

ORI NADAV
PATENT EXAMINER
TECHNOLOGY CENTER 2800